

TJK/180/L.W.

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8/20/01

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of Hong-Sik BYUN et al. ) PLASMA PROCESSING APPARATUS  
Korean Appln. No. 2000-30050 )  
Korean Filing Date: June 1, 2000 )

PRELIMINARY AMENDMENT

Assistant Commissioner for Patents  
Washington, D.C. 20231

Dear Sir:

Please amend the subject application as follows:

**--CROSS REFERENCE TO RELATED APPLICATION**

This application claims the priority of Korean patent application Serial No. 2000-30050  
filed on June 1, 2000.-

Respectfully submitted,

Date: 5/31/01  
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Melissa Paraday